

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Kazuya KAMON

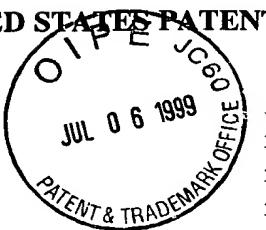
Application No.: 09/320,946

Filed: May 26, 1999

For: PHOTOMASK, FABRICATION METHOD  
OF PHOTOMASK, AND FABRICATION  
METHOD OF SEMICONDUCTOR  
INTEGRATED CIRCUIT

Group Art Unit: 1752

Examiner: Unassigned



**RECEIVED**

JUL - 7 1999

**GROUP 1752**

**INFORMATION DISCLOSURE STATEMENT  
TRANSMITTAL LETTER**

Assistant Commissioner for Patents  
Washington, D.C. 20231

Sir:

Enclosed is an Information Disclosure Statement and accompanying form PTO-1449 for the above-identified patent application.

- No additional fee for submission of an IDS is required.
- The fee of \$240.00 as set forth in 37 C.F.R. § 1.17(p) is also enclosed.
- A certification under 37 C.F.R. § 1.97(e) is also enclosed.
- A certification under 37 C.F.R. § 1.97(e), a petition requesting consideration of the information disclosure statement, and the petition fee of \$130.00 as set forth in 37 C.F.R. § 1.17(i) are also enclosed.
- Charge \$\_\_\_\_\_ to Deposit Account No. 02-4800 for the fee due.
- A check in the amount of \$\_\_\_\_\_ is enclosed for the fee due.

Information Disclosure Statement Transmittal Letter  
Application No. 09/320,946  
Attorney's Docket No. 027260-295  
Page 2

The Commissioner is hereby authorized to charge any appropriate fees under 37 C.F.R. §§ 1.16, 1.17 and 1.21 that may be required by this paper, and to credit any overpayment, to Deposit Account No. 02-4800. This paper is submitted in triplicate.

Respectfully submitted,

BURNS, DOANE, SWECKER & MATHIS, L.L.P.

By:

  
Charles F. Wieland III  
Registration No. 33,096

P.O. Box 1404  
Alexandria, Virginia 22313-1404  
(703) 836-6620

Date: July 6, 1999